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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/520,850	01/11/2005	John L. Glasper	124-1101	2666
	7590 03/14/200 NDERHYE, PC	EXAMINER		
901 NORTH G	LEBE ROAD, 11TH F	KO, TONY		
ARLINGTON,	VA 22203		ART UNIT	PAPER NUMBER
			2878	
SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
3 MONTHS		03/14/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

			Application No.	Applicant(s)			
Office Action Summary			10/520,850	GLASPER ET AL.			
		Office Action Summary	Examiner	Art Unit			
			Tony Ko	2878			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status .							
	1)	Responsive to communication(s) filed on					
			action is non-final.				
	3) Since this application is in condition for allowance except for formal matters, prosecution as to the mo						
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims							
	4)⊠	Claim(s) <u>1-11 and 25-36</u> is/are pending in the application.					
		4a) Of the above claim(s) 26-36 is/are withdraw	n from consideration.				
	5)	5) Claim(s) is/are allowed.					
	6)🛛	S)⊠ Claim(s) <u>1-4 and 8-11</u> is/are rejected.					
	7)⊠ Claim(s) <u>5-7 and 25</u> is/are objected to.						
	8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers							
	9)	The specification is objected to by the Examine	Г.	•			
	10)	The drawing(s) filed on is/are: a) ☐ acce	epted or b) objected to by the I	Examiner.			
		Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).			
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
	11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119							
	 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 						
		Certified copies of the priority documents		on No.			
3. Copies of the certified copies of the priority documents have been received in this National Stage							
application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the certified copies not received.							
				•			
At	tachmen	nt(s)					
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)							
	Information Inf	ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO/SB/08) er No(s)/Mail Date 12/27/06.	Paper No(s)/Mail D 5) Notice of Informal F 6) Other:				
		•					

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DETAILED ACTION

Specification

1. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.

Election/Restrictions

2. Newly submitted claims 26-36 are directed to an invention that is independent or distinct from the invention originally claimed for the following reasons: two different embodiments once require a third layer of insulating layer and the other does not.

Since applicant has received an action on the merits for the originally presented invention, this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, claims 26-36 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

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4. Claims 1 rejected under 35 U.S.C. 102(e) as being anticipated by Marshall (U.S. Patent 6,858,912).

- 5. Regarding claim 1, Marshall discloses (Figs. 19 and 20) a method of making a photodetector circuit incorporating a photodiode, the method including the steps of: providing a first electrically insulating layer on a semiconductor substrate (602); forming a first window (604) in the first insulating layer exposing an area of the substrate within the first window; forming a guard ring (612) in the exposed area of the substrate within the first window; providing a second electrically insulating layer (618) covering the exposed area of the substrate within the first window; forming a second window in the second insulating layer exposing a selected area of the substrate within the first window (Col. 17, Lines 30-40); growing on the selected area of the substrate exposed by the second window an epitaxial layer providing an active region of the photodiode detector suchs that the edges of the epitaxial layer are spaced from the inner periphery of the first window; and removing any remaining portion of said second insulating layer (Col. 17, lines 19-60).
- 6. Regarding claim 2, Marshall discloses the extent of the windows is such that the guard ring is overlapped by the edges of the epitaxial layer. (Fig. 20).
- 7. Regarding claim 3, Marshall discloses (Fig. 20) the second window is formed in the second insulating layer so as to leave a portion of the second insulating layer within the inner periphery of the first window which ensures, during growth of the epitaxial layer, that the edges of the epitaxial layer are spaced from the inner periphery of the first window.

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8. Regarding claim 8, Marshall discloses the step of growing on top of the first mentioned epitaxial layer (614) a further epitaxial layer (616) having a higher doping level than the first mentioned epitaxial layer.

- 9. Regarding claim 9, Marshall discloses the further epitaxial layer (620) contacts the substrate so as to be in ohmic contact with the guard ring in the substrate.
- 10. Regarding claim10, Marshall discloses the photodiode detector is an avalanche photodiode. (Abstract)
- 11. Regarding claim 11, Marshall discloses wherein readout circuitry (606) is formed on the first insulating layer.

Claim Rejections - 35 USC § 103

- 12. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 13. Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over Marshall in view of Harari (U.S. Patent 5,198,380).
- 14. Regarding claim 4, Marshall discloses the invention set forth above. Marshal does not teach wet etch. Harari discloses the use of wet etch. It is well know to apply wet etch. It would have been obvious to a person of ordinary skill in the art at the time of the invention to wet etch the layer to precise etch away the undesired layers.

Allowable Subject Matter

- 15. Claims 5-7 and 25 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 16. The following is a statement of reasons for the indication of allowable subject matter: Prior art does not disclose a further electrically insulating layer is provided on the first insulating layer covering the first window, and a further window is formed in the further insulating layer to expose a selected area of the substrate within the first window prior to the forming of the second insulating layer covering the exposed area of the substrate within the first window.

Conclusion

17. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tony Ko whose telephone number is 571-272-1926. The examiner can normally be reached on Monday-Friday 7:30 - 4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Georgia Epps can be reached on 571-272-2328. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

> THANH X. LUU PRIMARY EXAMINER

TKO